

# **Lawrence Berkeley National Laboratory**

## Lawrence Berkeley National Laboratory

### **Title**

Erratum: High power impulse magnetron sputtering: Current-voltage-time characteristics indicate the onset of sustained self-sputtering

### **Permalink**

<https://escholarship.org/uc/item/93r6602s>

### **Authors**

Anders, Andre  
Andersson, Joakim  
Ehiasarian, Arutiun

### **Publication Date**

2008-05-20

**Erratum: High power impulse magnetron sputtering: Current-voltage-time  
characteristics indicate the onset of sustained self-sputtering**

André Anders<sup>a)</sup>, Joakim Andersson

Lawrence Berkeley National Laboratory, University of California, 1 Cyclotron Road,  
Berkeley, California 94720

Arutiu Ehiasarian

Materials and Engineering Research Institute, Sheffield Hallam University, Howard St.,  
Sheffield S1 1WB, UK

We noticed that Figures 1 and 2 of the original publication showed data of preliminary measurements that are not quite consistent with the text and figure captions.

We regret this mistake and provide here the correct figures.

<sup>a)</sup>Corresponding author; Electronic mail aanders@lbl.gov

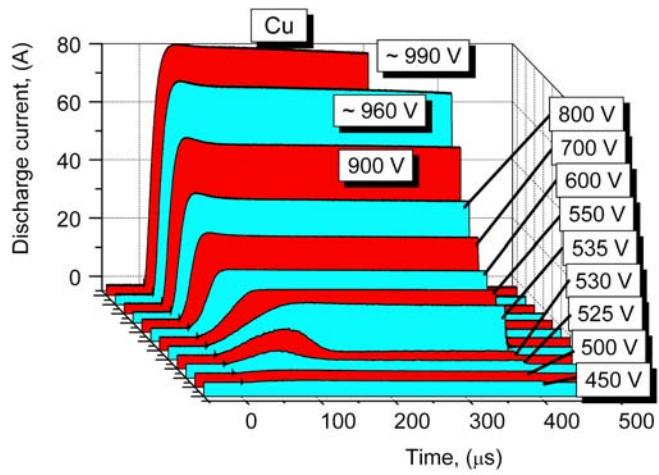


Fig. 1

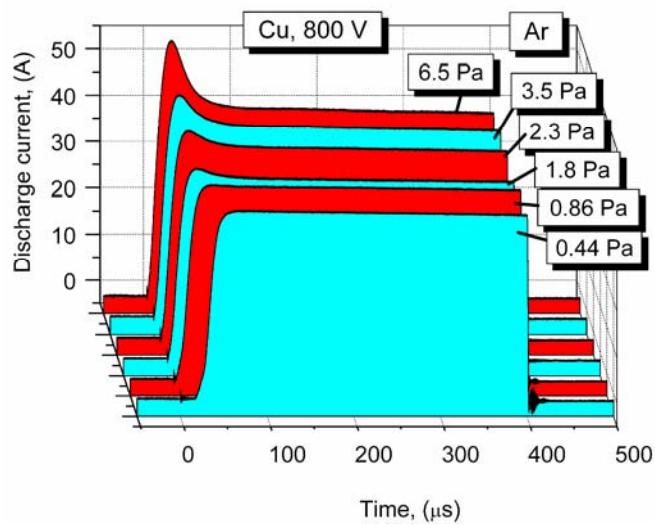


Fig. 2